



ECE 111

Carrier motion in Semiconductors

Drift and diffusion currents (2)

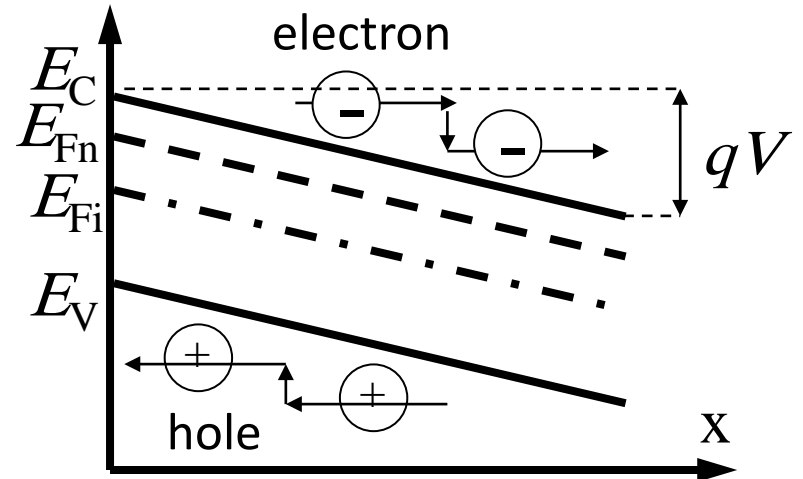
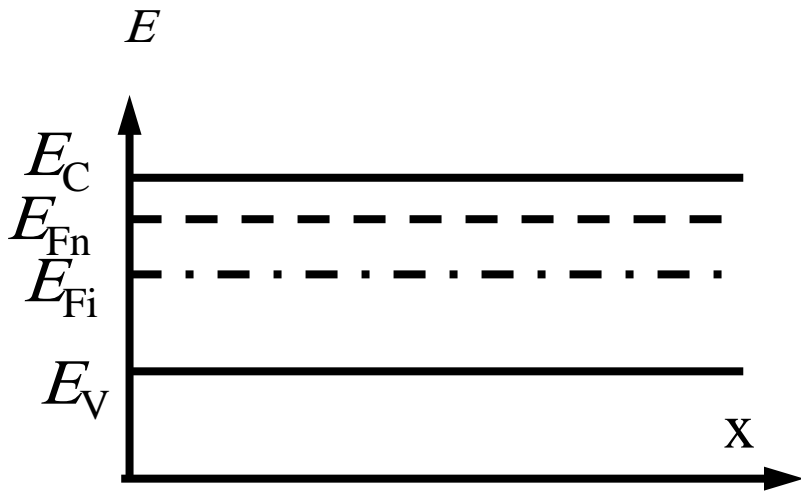
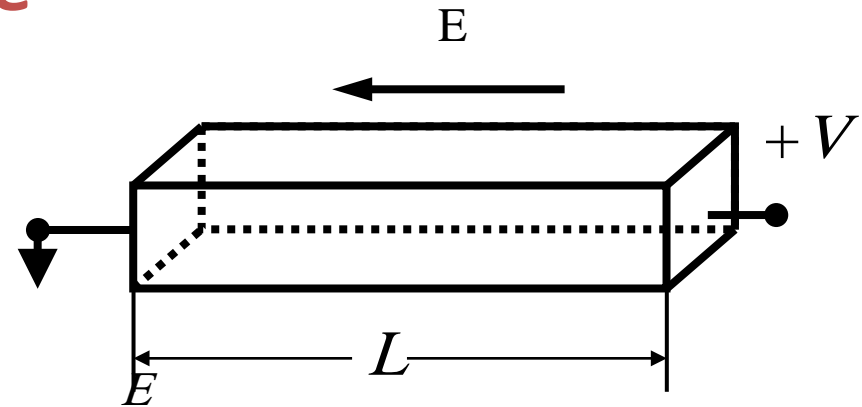
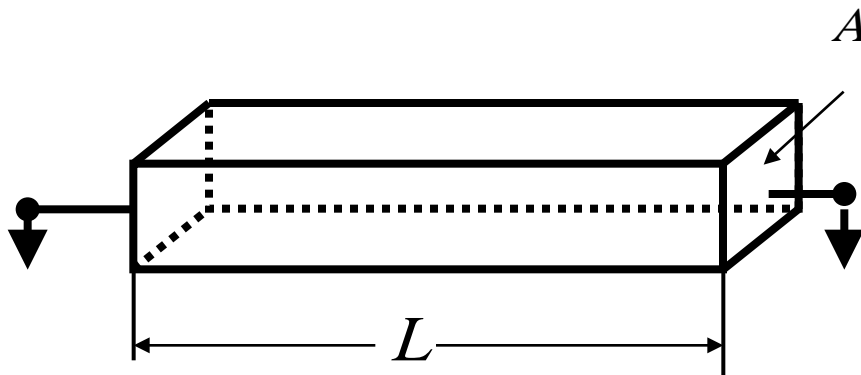
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Drift Current



The current produced by the transport of carriers under the influence of an applied electric field is called the **drift current**.

N-type



Electric potential



$$-q\mathbf{E} = -\frac{dE_C}{dx} = -\frac{dE_i}{dx} = -\frac{dE_V}{dx}$$



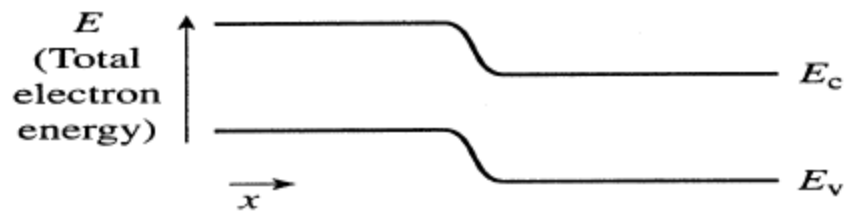
Relation between Electric field and electric potential

$$\mathbf{E} = \frac{1}{q} \frac{dE_C}{dx} = \frac{d}{dx} \left(\frac{1}{q} E_{Fi} \right) \quad \mathbf{E} \equiv -\frac{d\varphi}{dx}$$



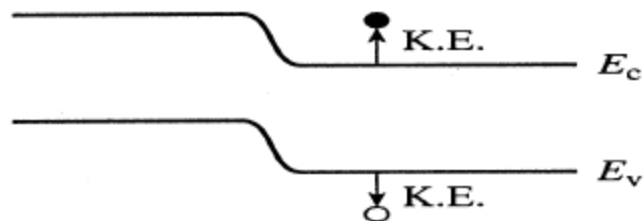
$$\varphi = -\frac{E_{Fi}}{q}$$

Band Bending



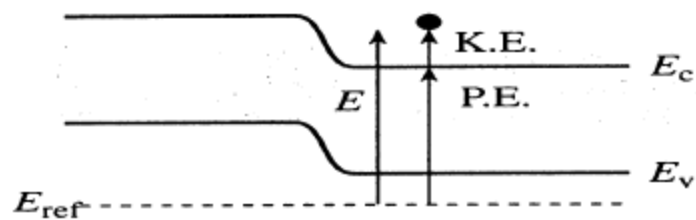
(a)

(a) Sample energy band diagram;



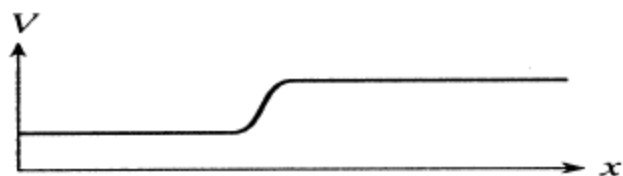
(b)

(b) Carrier kinetic energies;



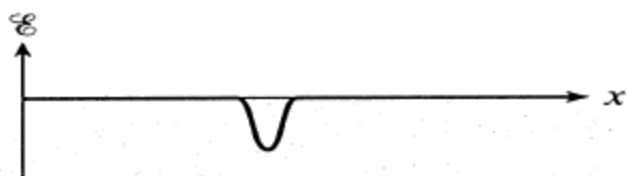
(c)

(c) Electronic potential energy;



(d)

(d) Potential;



(e)

(e) Electric field.

drift current density



$$v_n = -\mu_n \mathbf{E}$$

$$v_p = \mu_p \mathbf{E}$$

$$J_n = -q n v_n = q n \mu_n \mathbf{E}$$

$$J_p = q p v_p = q p \mu_p \mathbf{E}$$

$$J = J_n + J_p = q(n\mu_n + p\mu_p)\mathbf{E}$$

$$J = q(n\mu_n + p\mu_p)\mathbf{E}$$

$$\sigma = q(n\mu_n + p\mu_p)$$

$$\rho = \frac{1}{\sigma}$$

Ohm's law:

$$J = \sigma \mathbf{E}$$



Diffusion & Diffusion Current Density

Diffusion in semiconductors



So far we considered the drift motion of carriers in semiconductors due to applied electric fields. That motion gives rise to drift current.

- ❑ There is another type of current in semiconductors that arises due to the **diffusion of carriers**. Diffusion is also a consequence of random thermal motion of carriers. But the exact source of diffusion is the **non-uniform spatial distribution of carriers**.
- ❑ We have assumed so far that the carrier concentration distribution is uniform everywhere inside the semiconductor. This may not always be true. For example, the impurity distribution inside a semiconductor may vary due to processing conditions. There may be different types of impurities in different regions that will also give rise to non-uniform carrier distribution.
- ❑ Let us now analyze the consequence of non-uniform distribution of carriers.

Origin of diffusion Concentration gradients

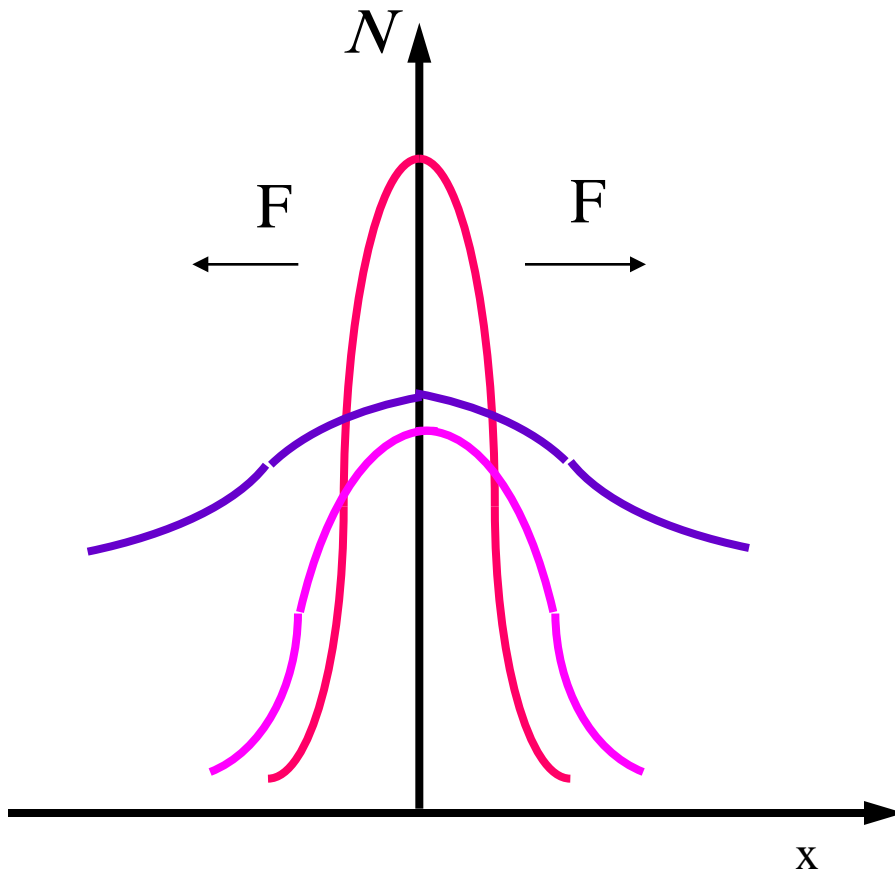


- ❑ When the carrier concentration is uniform everywhere inside a semiconductor sample, the carriers **move in and out** of any small region at the same rate due to the random thermal motion.
- ❑ However, when carrier concentration is non-uniform, **more** number of **carriers move out** of the higher carrier concentration region **than** the number of **carriers that move into** it. As a result, there is a net motion of carriers from the higher concentration region to a lower concentration region. Thermal agitation causes the carriers to spread in such a way as to equalize the distribution. This motion of carriers is known as the **diffusion**.
- ❑ Thus, the two main factors that are responsible for diffusion are **the thermal agitation** and the **concentration differences**.

diffusion



Fick's law describes diffusion as the flux, F , (of particles in our case) is proportional to the gradient in concentration.



$$F = -D \frac{dN}{dx}$$

F – flux of carriers

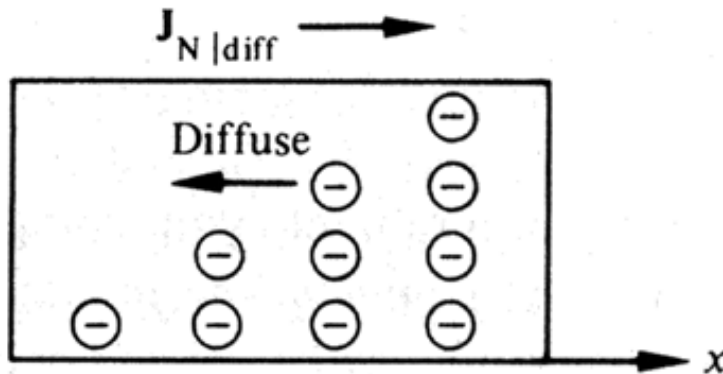
N – carrier density

D – diffusion constant
(diffusivity)

Diffusion current

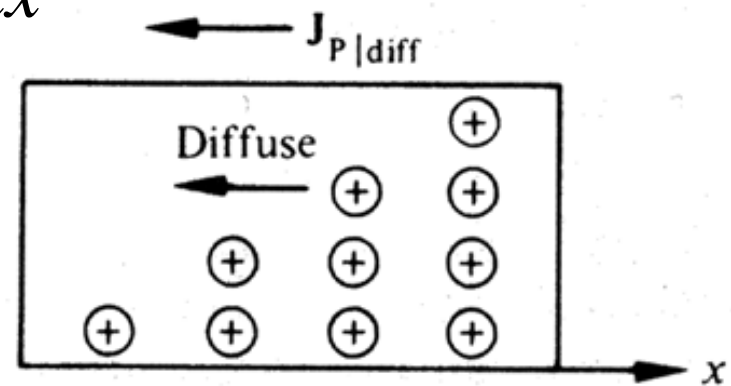


$$Flux = F = -D \frac{dN}{dx}$$



$$J_{ndiff} = -q \left(-D_n \frac{dn}{dx} \right)$$

$$J_n = qD \frac{dn}{dx}$$



$$J_p = -qD_p \frac{dp}{dx}$$

Diffusion current



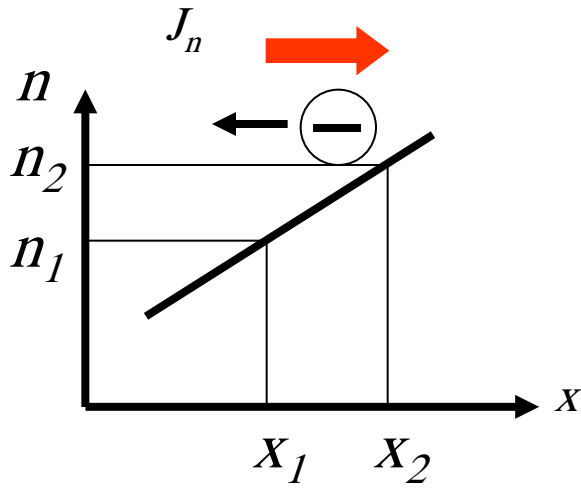
Electrons

$$J_n = qD_n \frac{dn}{dx}$$

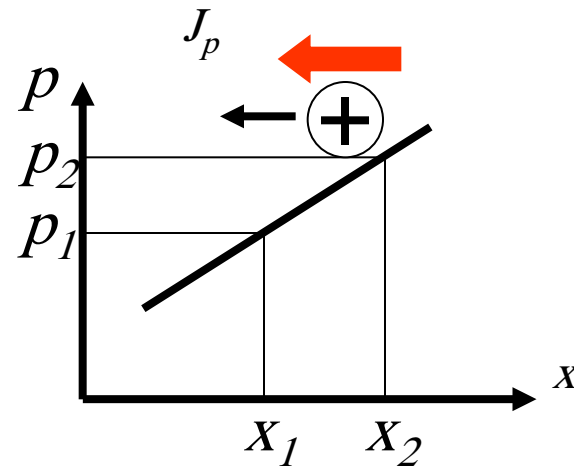
Holes

$$J_p = -qD_p \frac{dp}{dx}$$

D_n diffusion constants for electrons



D_p diffusion constants for holes



Einstein's relationship



$$n = n_i \exp\left(\frac{E_F - E_i}{kT}\right) \quad \mathbf{E} = \frac{1}{q} \frac{dE_i}{dx}$$

for thermal equilibrium: $J_n = q\mu_n n \mathbf{E} + qD_n \frac{dn}{dx} = 0$

~~$$q\mu_n n_i \exp\left[\frac{E_F - E_i}{kT}\right] \frac{1}{q} \frac{dE_i}{dx} = -\frac{q}{kT} D_n n_i \exp\left[\frac{E_F - E_i}{kT}\right] \left[\frac{dE_F}{dx} - \frac{dE_i}{dx}\right]$$~~

$$\mu_n = \frac{qD_n}{kT}$$

$$\frac{D_n}{\mu_n} = \frac{kT}{q} = V_T$$

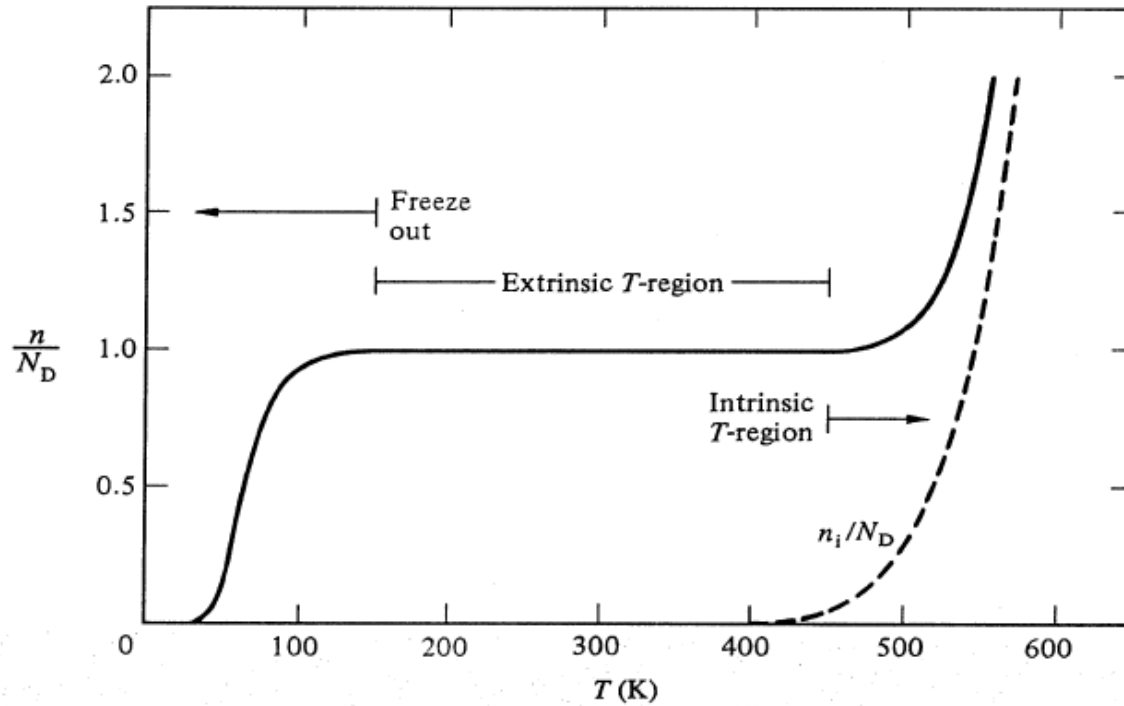
V_T thermal potential

$$\frac{dE_F}{dx} = 0$$

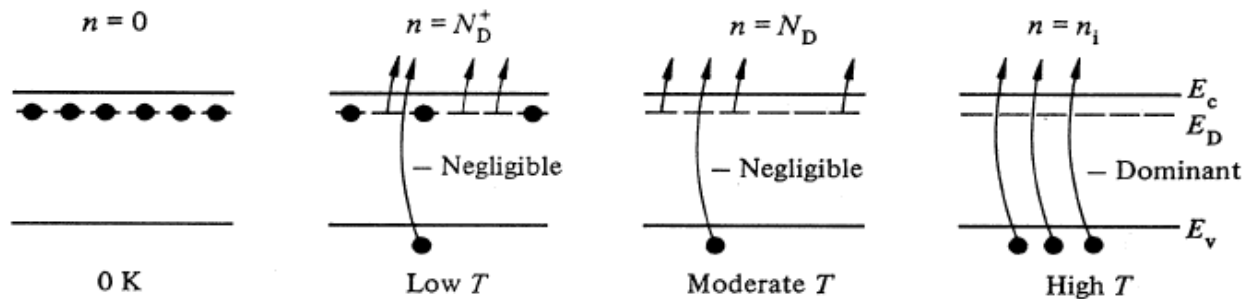
Good luck

Note: (Carriers at equilibrium)

Carrier Concentration Temperature Dependence



(a)



(b)

Temperature dependence of carrier concentrations



- ❑ **Freeze-out region:** (Very low temperatures, typically below 100K) Carrier concentration gradually increases as the T is increased as the impurity ionization increases.
- ❑ **Extrinsic region:** (intermediate temperatures) – Ionization of the impurities is complete. Carrier concentration is constant. Intrinsic carrier concentration is much smaller than the doping concentration.
- ❑ **Intrinsic region:** (Very high temperatures) – Intrinsic carrier concentration is higher than the doping concentration. Electron and hole concentrations are equal. The material behaves as if intrinsic.